

С П И С Ъ К
 на цитирания на научните трудове на
чл.-кор. дфн ГЕОРГИ МИХАЙЛОВ МЛАДЕНОВ
 от Институт по електроника при БАН

**I. ЦИТИРАНИЯ НА ПУБЛИКАЦИИ И АВТОРСКИ СВИДЕТЕЛСТВА,
ВКЛЮЧЕНИ В ДИСЕРТАЦИОННИТЕ РАБОТИ**

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考虑到焊接过程中存在的高温金属蒸气等离子体及真空电子束焊接
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